

Exploring JMP DOE design and modeling functions to improve sputtering process

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Agenda - Six Sigma DMAIC Black Belt Project (using JMP)

Define

- **CTQ1 ≥ 0.5 (!)**
- **CTQ2 ≤ 0.05**
- **CTQ3 ≤ 0.05**

Measure

- Measurement system assessment
- Baseline hardware
 - 3 tuning knobs (X_1, X_2, X_3)
- Baseline capability analysis
 - ✓ Monte-Carlo simulation
- Baseline model establish
 - ✓ Augment DOE
 - ✓ RSM
 - ✓ Prediction profile
 - ✓ Interaction profile

Analyze

- Root cause and capability analysis
 - ✓ Goal plot
 - ✓ Desirability function
 - ✓ Multivariate method
 - ✓ Graphic analysis

Improve

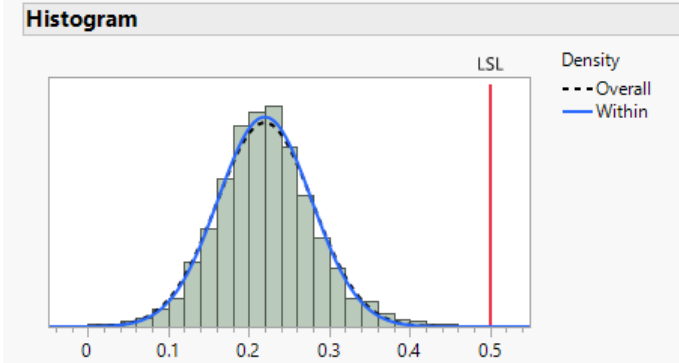
- Hardware modification
 - Introduce X_4
- Process improvement
 - ✓ Interactive graph
 - ✓ Augment DOE
 - ✓ RSM
 - ✓ Desirability function
 - ✓ Interaction profile
- Robust DOE Modeling
 - ✓ GOSS
 - ✓ Stepwise fit
 - ✓ Desirability function

Control

- Control plan and control method
- Knowledge transfer

Baseline capability – Monte Carlo Simulation

CTQ1: LSL ≥ 0.5



Process Summary

LSL	0.5
N	10000
Sample Mean	0.219963
Within Sigma	0.058054
Overall Sigma	0.059695
Stability Index	1.028264

- Sample mean outside spec limit, -ve Ppk
- Baseline process result can not meet CTQ1 spec

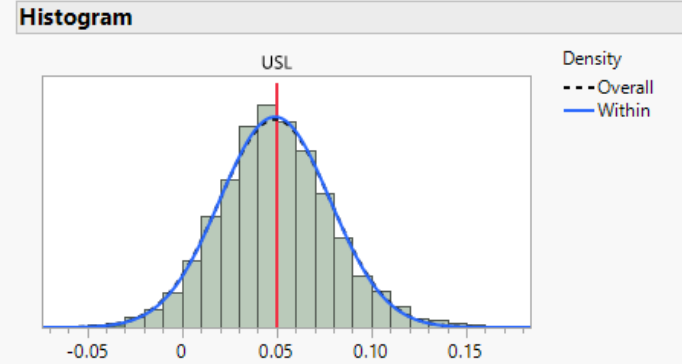
Overall Sigma Capability

Index	Estimate	Lower 95%	Upper 95%
Ppk	-1.564	-1.586	-1.541
Ppl	-1.564	-1.586	-1.541

Nonconformance

Portion	Observed %	Expected Within %	Expected Overall %
Below LSL	99.9900	99.9999	99.9999
Total Outside	99.9900	99.9999	99.9999

CTQ2: USL ≤ 0.05



Process Summary

USL	0.05
N	10000
Sample Mean	0.049091
Within Sigma	0.029074
Overall Sigma	0.029391
Stability Index	1.010887

- Sample mean ~ upper spec limit, Ppk ~ 0
- 48% of baseline process result did not meet CTQ2 spec

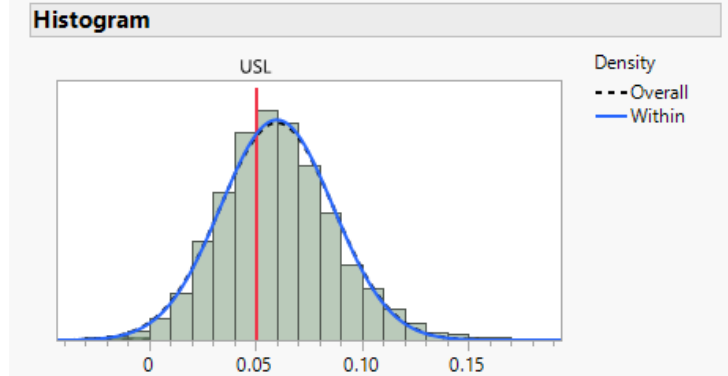
Overall Sigma Capability

Index	Estimate	Lower 95%	Upper 95%
Ppk	0.010	0.004	0.017
Ppu	0.010	0.004	0.017

Nonconformance

Portion	Observed %	Expected Within %	Expected Overall %
Above USL	47.2900	48.7536	48.7670
Total Outside	47.2900	48.7536	48.7670

CTQ3: USL ≤ 0.05



Process Summary

USL	0.05
N	10000
Sample Mean	0.060028
Within Sigma	0.026427
Overall Sigma	0.026759
Stability Index	1.012573

- Sample mean outside spec limit, -ve Ppk
- 64% of baseline process result did not meet CTQ3 spec

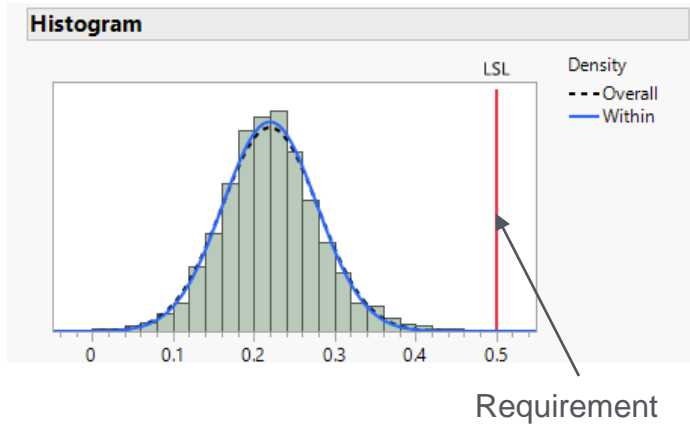
Overall Sigma Capability

Index	Estimate	Lower 95%	Upper 95%
Ppk	-0.125	-0.132	-0.118
Ppu	-0.125	-0.132	-0.118

Nonconformance

Portion	Observed %	Expected Within %	Expected Overall %
Above USL	63.6800	64.7835	64.6085
Total Outside	63.6800	64.7835	64.6085

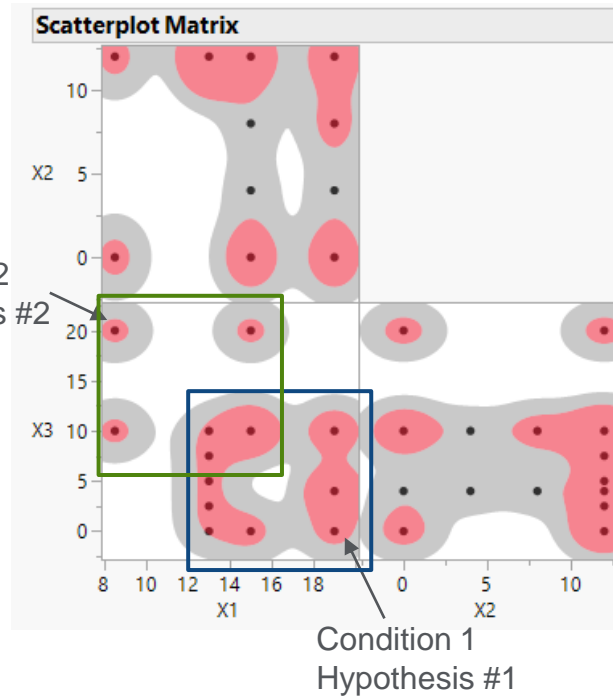
Baseline condition @ baseline model – design evaluation



Baseline capability:

- Baseline process (condition 1) cannot meet the CTQ1 requirement
- Need to determine if the hardware has the capability to meet requirement for CTQ1
- Subject matter expert (SME) advised shift process condition 1 to process condition 2 based on hypothesis #2

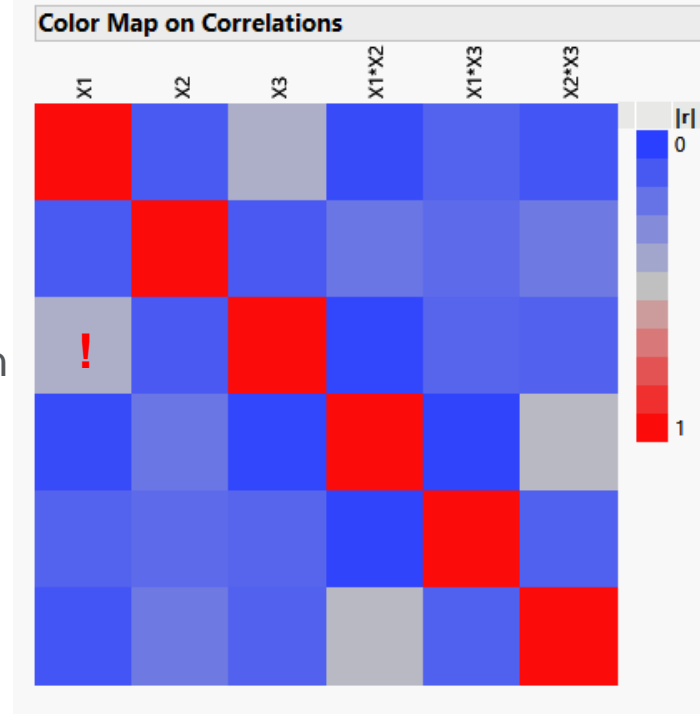
Process tuning



Design evaluation

Confounding Analysis:

- Resolution II: $X_1 + X_3$ @ 0.4352
- Resolution III: low confounding risk

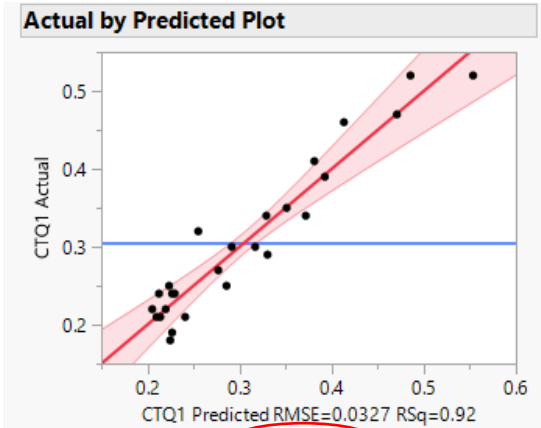


Scatterplot Analysis:

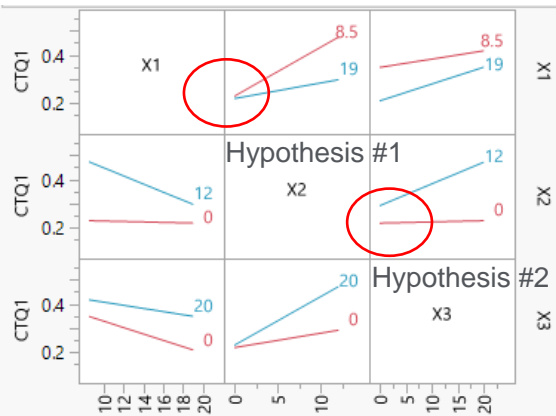
- Data collected not in orthogonal structure
- 2 step evolution design
- Widen the process range to meet spec for CTQ1
- Weak prediction capability in white area
- Good prediction for condition 1 & 2

Baseline condition @ baseline model – RSM

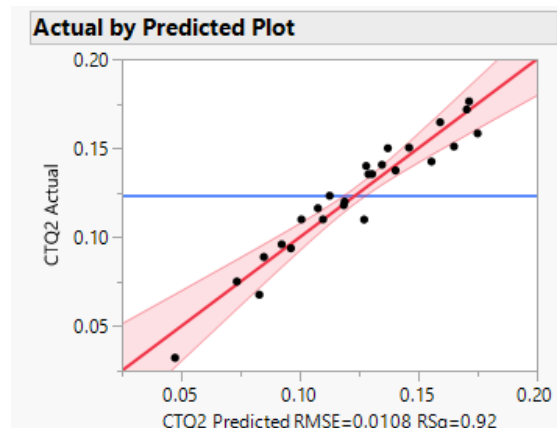
CTQ1



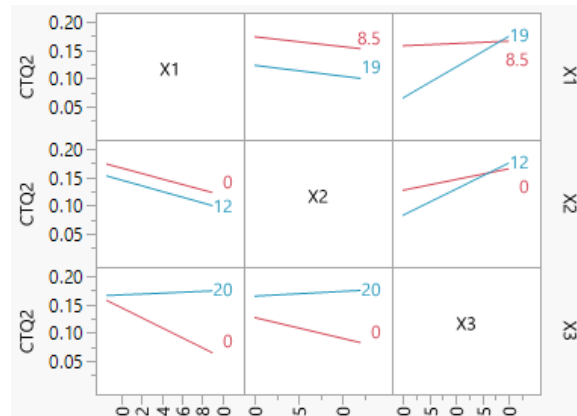
Summary of Fit	
RSquare	0.921232
RSquare Adj	0.896357
Root Mean Square Error	0.032657
Mean of Response	0.305385
Observations (or Sum Wgts)	26



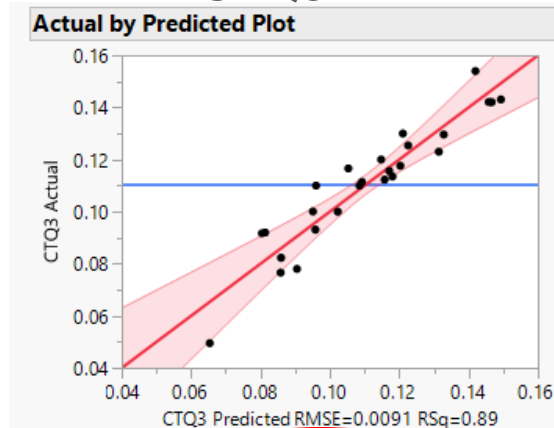
CTQ2



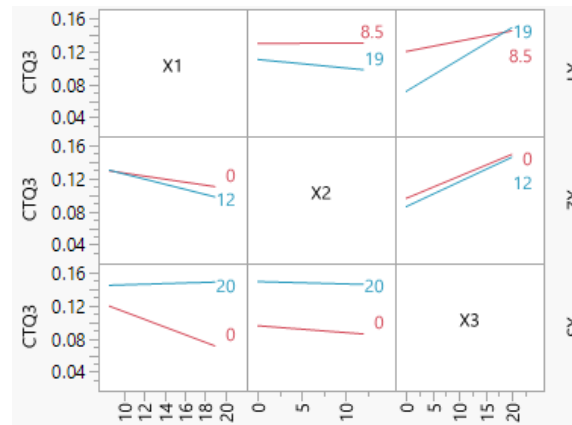
Summary of Fit	
RSquare	0.923404
RSquare Adj	0.899215
Root Mean Square Error	0.010787
Mean of Response	0.123657
Observations (or Sum Wgts)	26



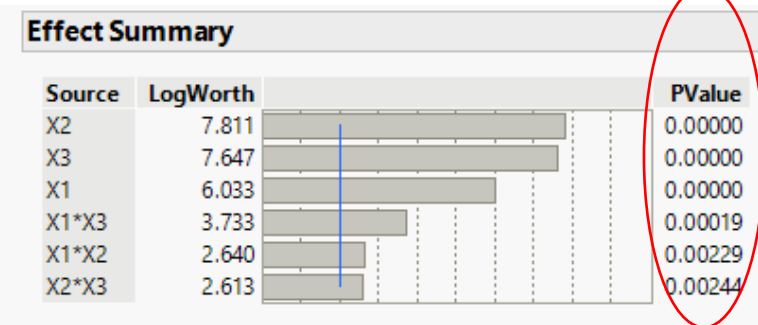
CTQ3



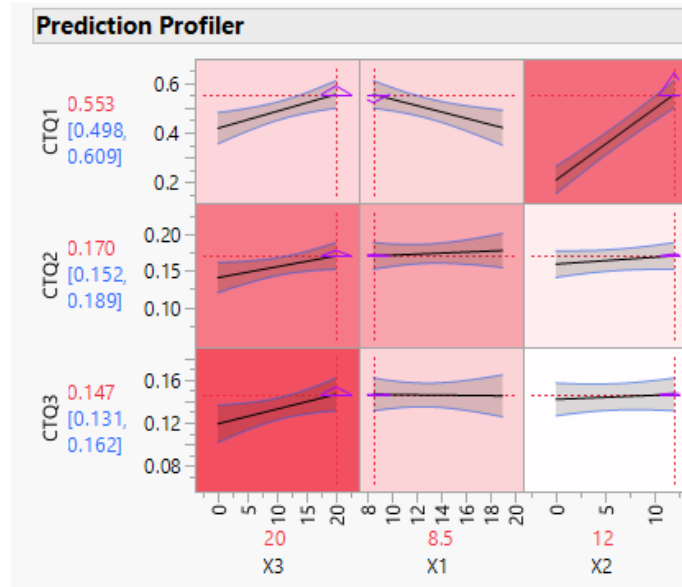
Summary of Fit	
RSquare	0.889566
RSquare Adj	0.854692
Root Mean Square Error	0.009092
Mean of Response	0.110749
Observations (or Sum Wgts)	26



Effect Summary



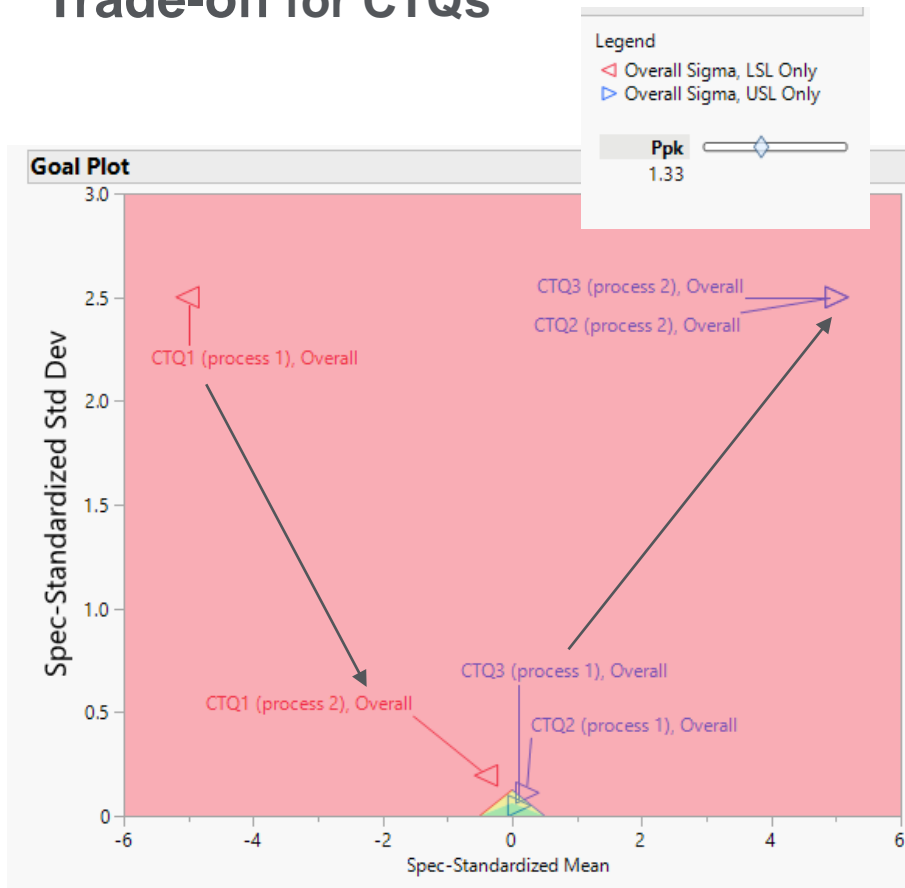
Improved CTQ1?



- 95% confidence interval of CTQ1 is (49.8%~60.9%)

Optimized solution: maximize desirability for (baseline model; N.A)

Trade-off for CTQs

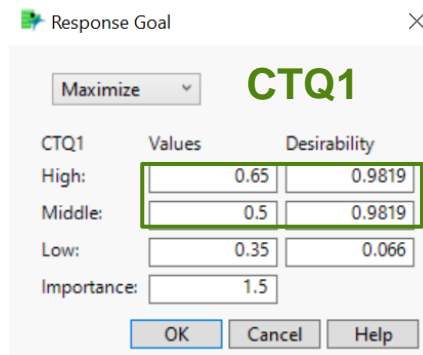


Process condition 1 → process condition 2:

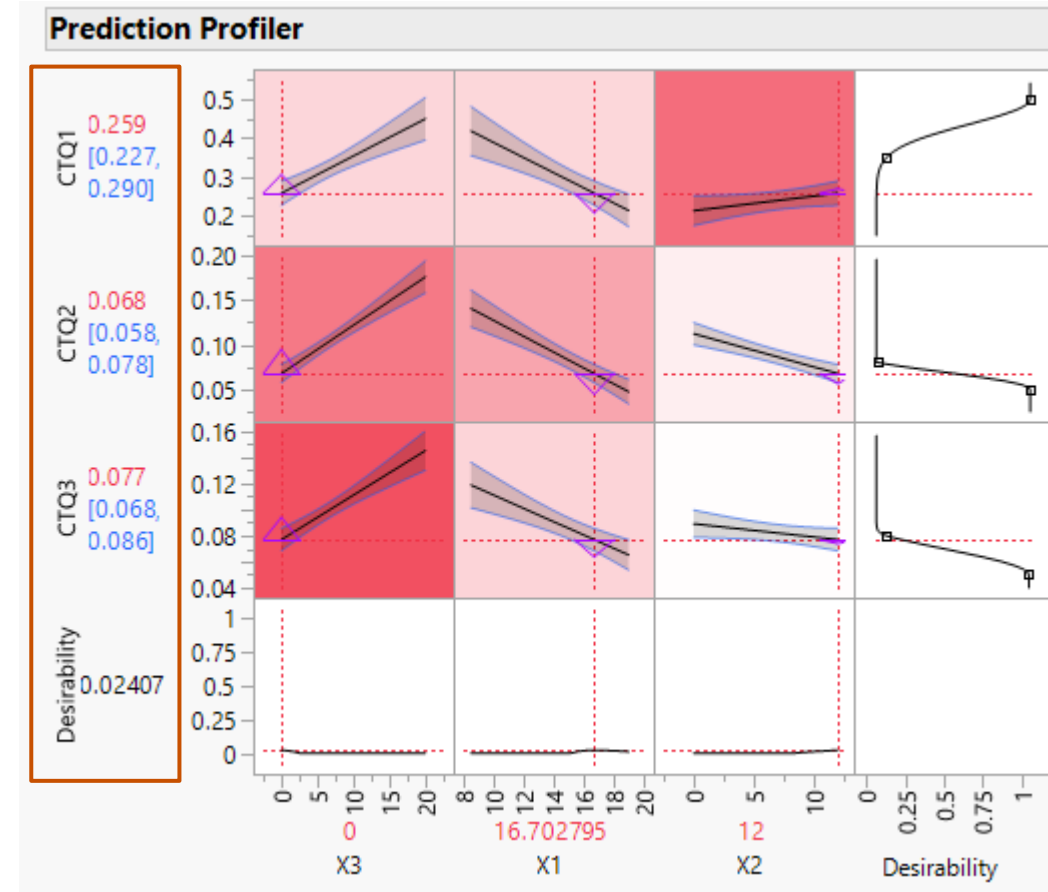
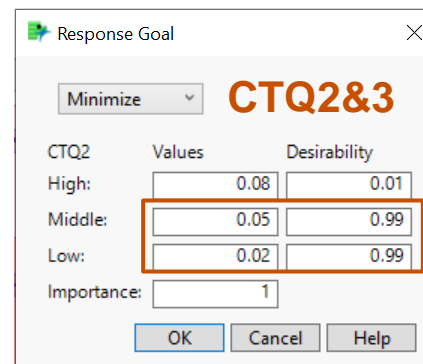
- Improve CTQ1
- Compensate CTQ 2&3

Find optimized solution via desirability function

For CTQ1:
 Maximum plateau
 (any value \geq target is equally preferred)

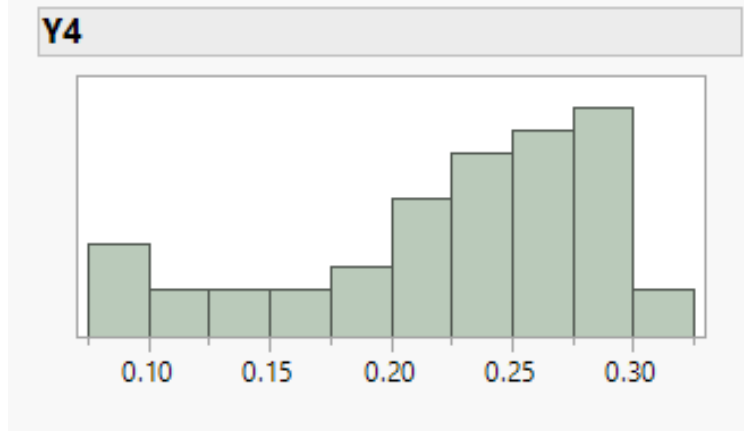


For CTQ2&3:
 Minimum plateau
 (any value \leq target is equally preferred)



- ☹ 0.02 desirable
- ☹ no CTQ meet success criteria
- ☹ Hardware limitations

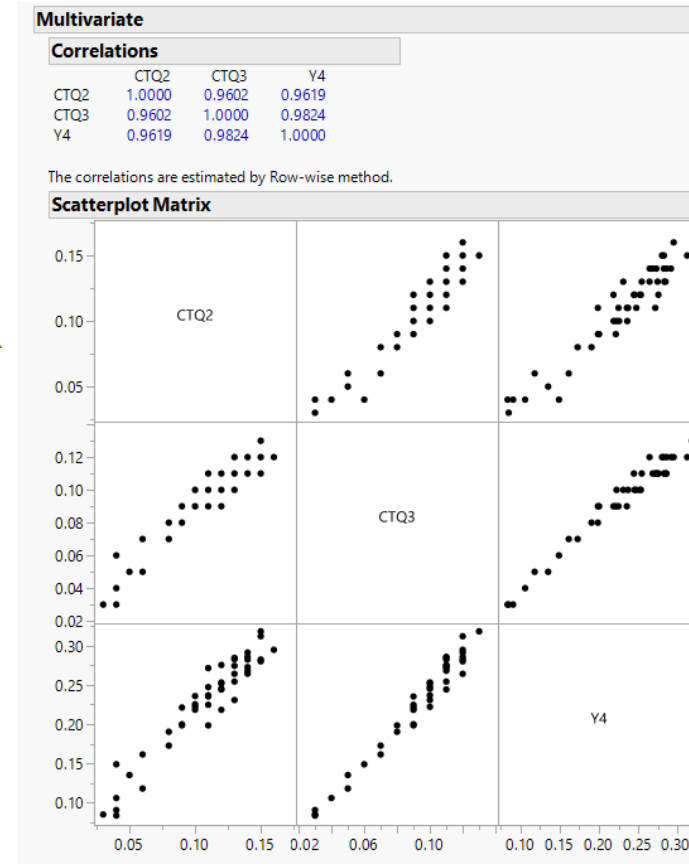
Y_4 & X_4



SME decided to introduce Y_4 , a measurable

- Reflects process intrinsic property
- Affects CTQ2 & CTQ3
- $Y_4 > 0$, +ve process
- $Y_4 < 0$, -ve process
- $Y_4 \sim 0$, neutral process \rightarrow smaller CTQ2 & CTQ3

Smaller Y_4 : smaller CTQ2 & CTQ3

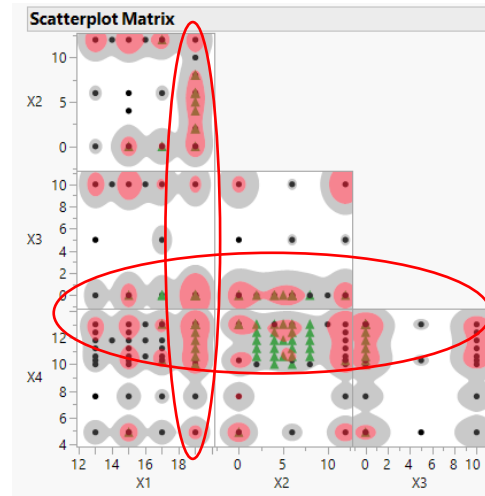
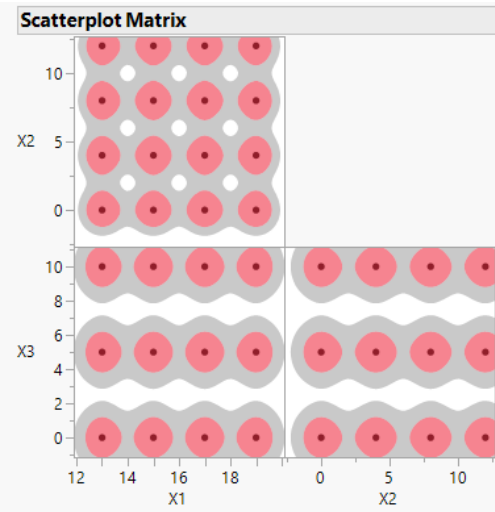


Next: add in X_4 impact Y_4
(Hypothesis #3 & Hypothesis #4)

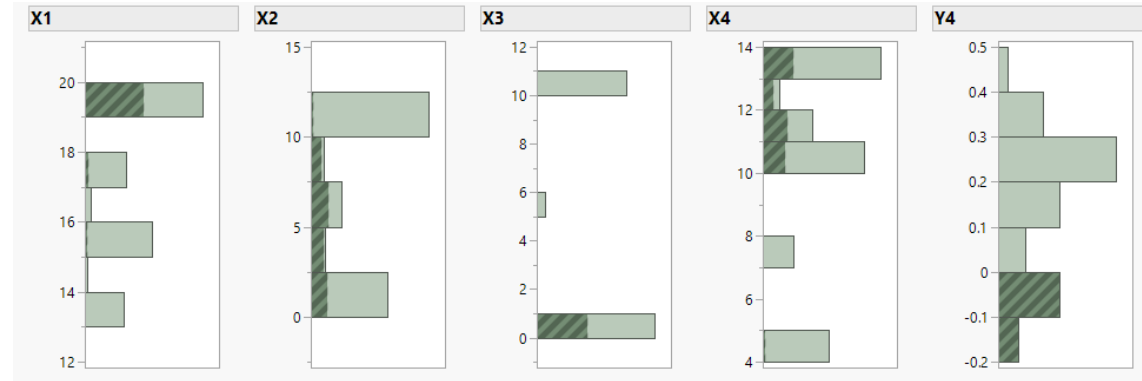
Validate X_4 impact on CTQ2&3

Without X_4

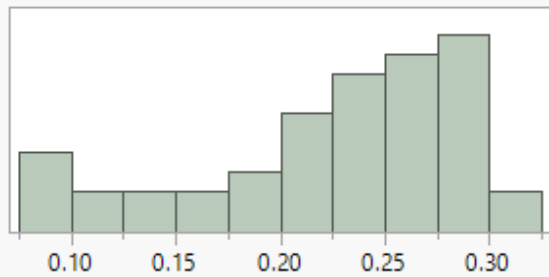
With X_4



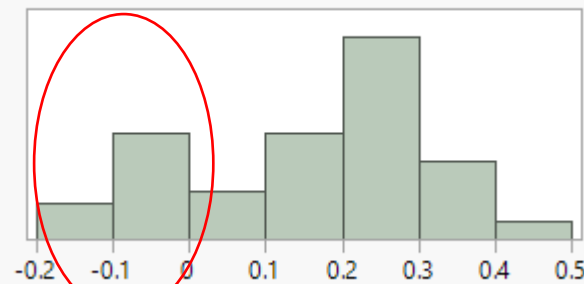
Simple screen of conditions for $Y_4 < 0$:
-ve process



Y4 (without X4)



Y4 (with X4)



Tuning range (orthogonal)

- X1: 13~19
- X2: 0~12
- X3: 0~10

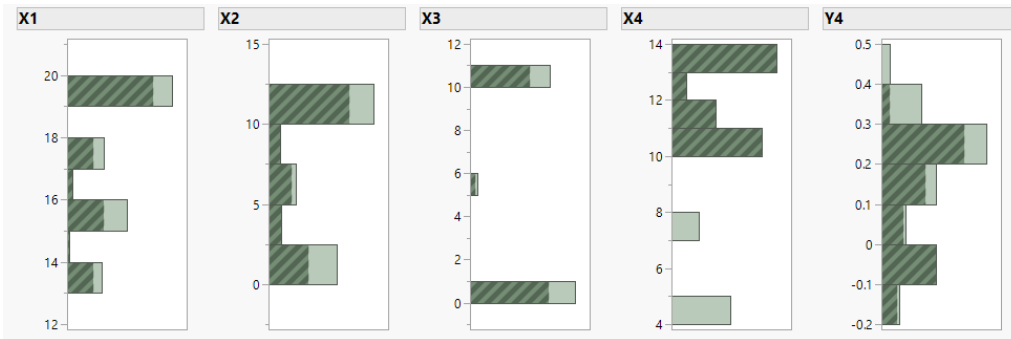
Tuning range

- X1: 13~19
- X2: 0~12
- X3: 0~10
- X_4 : 5~13

- X_4 has impact on $Y_4 \rightarrow$ can impact CTQ 2&3
- Wide range of Y_4 , potential solution with two step process

Analyze & improve model: design evaluation (CTQ1, 2 &3)

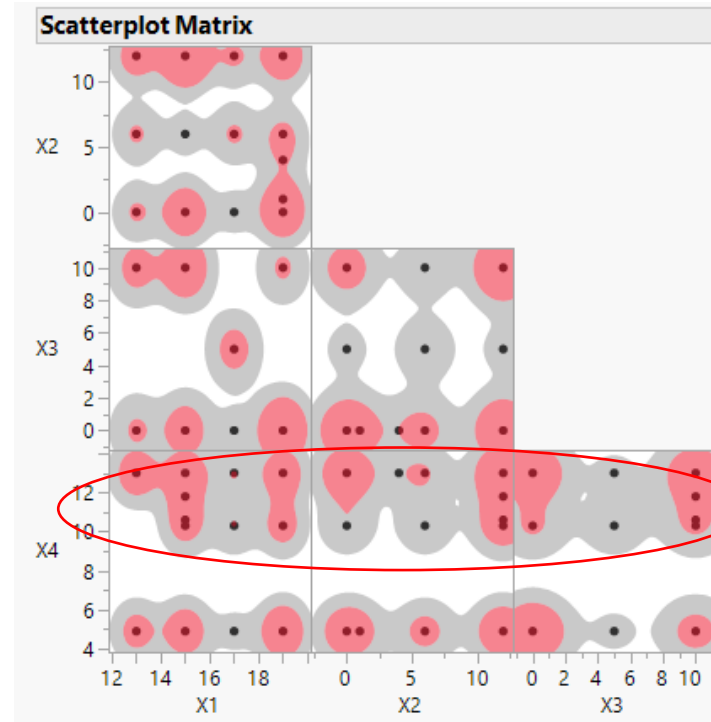
Prescreening



Prior data collection

- Validated X_4
- Prescreen conditions of interest (higher value of X_4)
- Provide most Y_4 conditions
- X_4 might have interactions with other X s

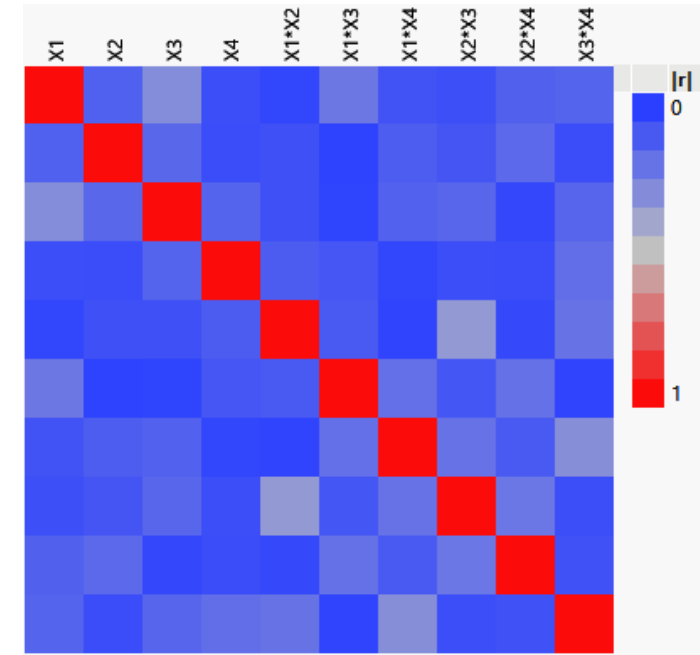
Data collection



Scatterplot Analysis:

- Wide range (with X_4)
- More data collected at conditions of interest
- Not most orthogonal structure

Design evaluation

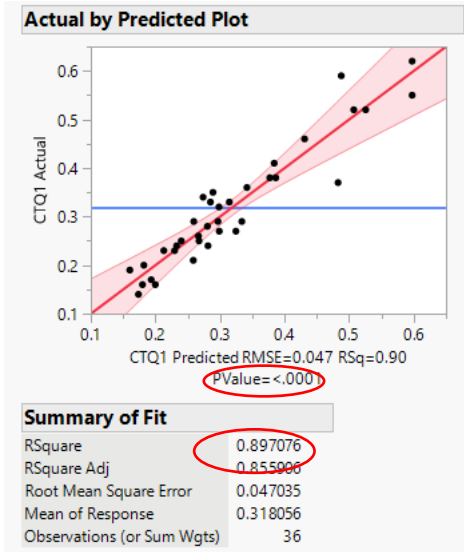


Confounding Analysis:

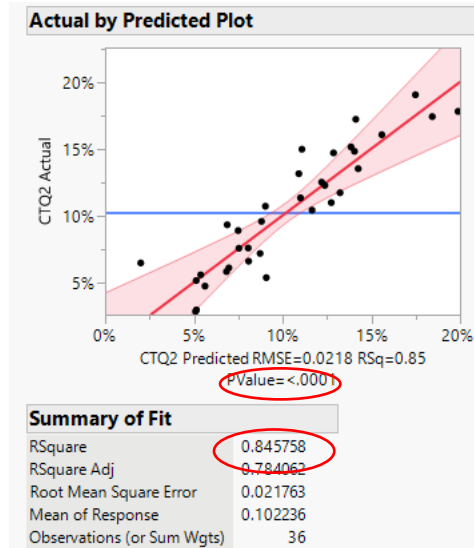
- Low confounding risk
- Data structure good for modelling

Analyze & improve model: model evaluation (CTQ1, 2 &3)

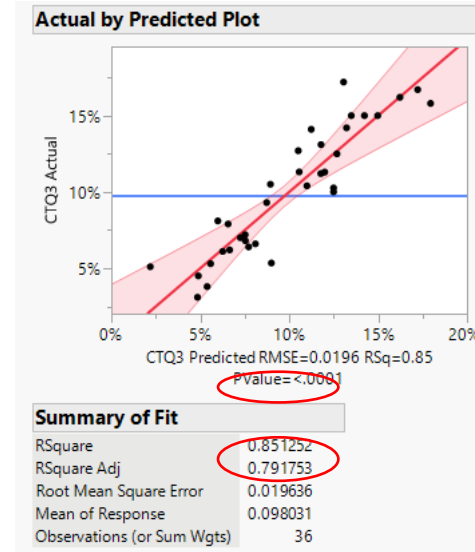
CTQ1



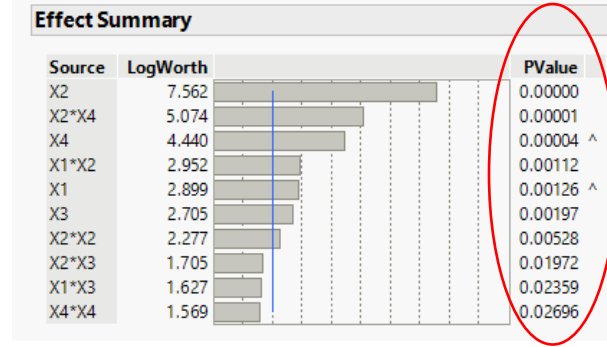
CTQ2



CTQ3

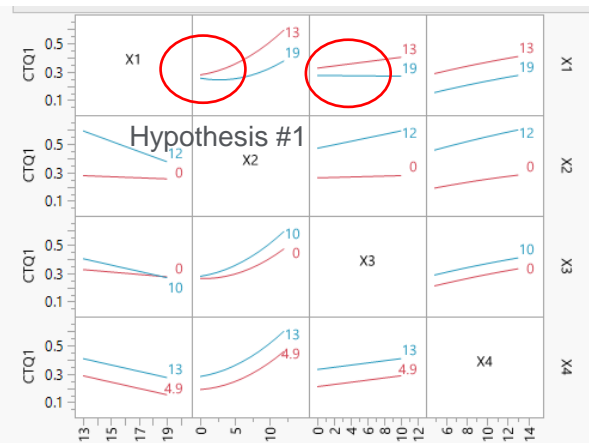


Effect Summary

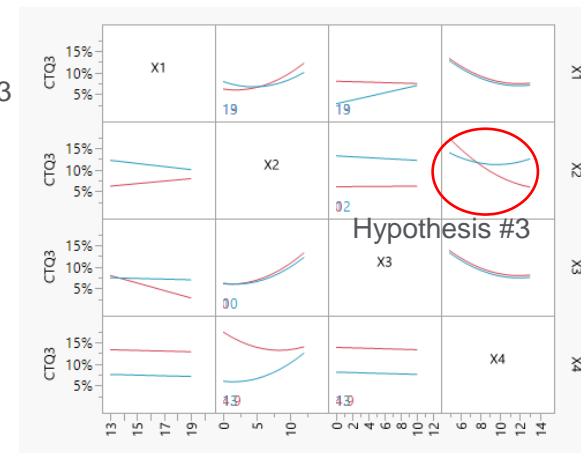
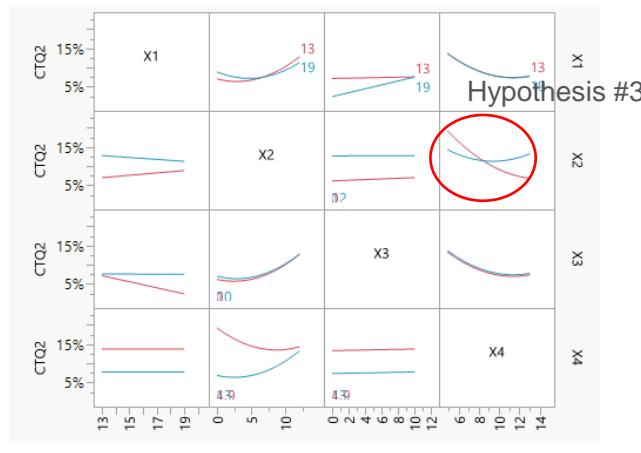


- Only factor with Pvalue<math>< 0.05</math> included in model
- Rsquare > 80%; Rsquare-Rsquare Adj < 10%, Pvalue = <math>< .0001</math>; adequate models
- Hypothesis #1~#4 validated with interaction profilers

Optimized solution?

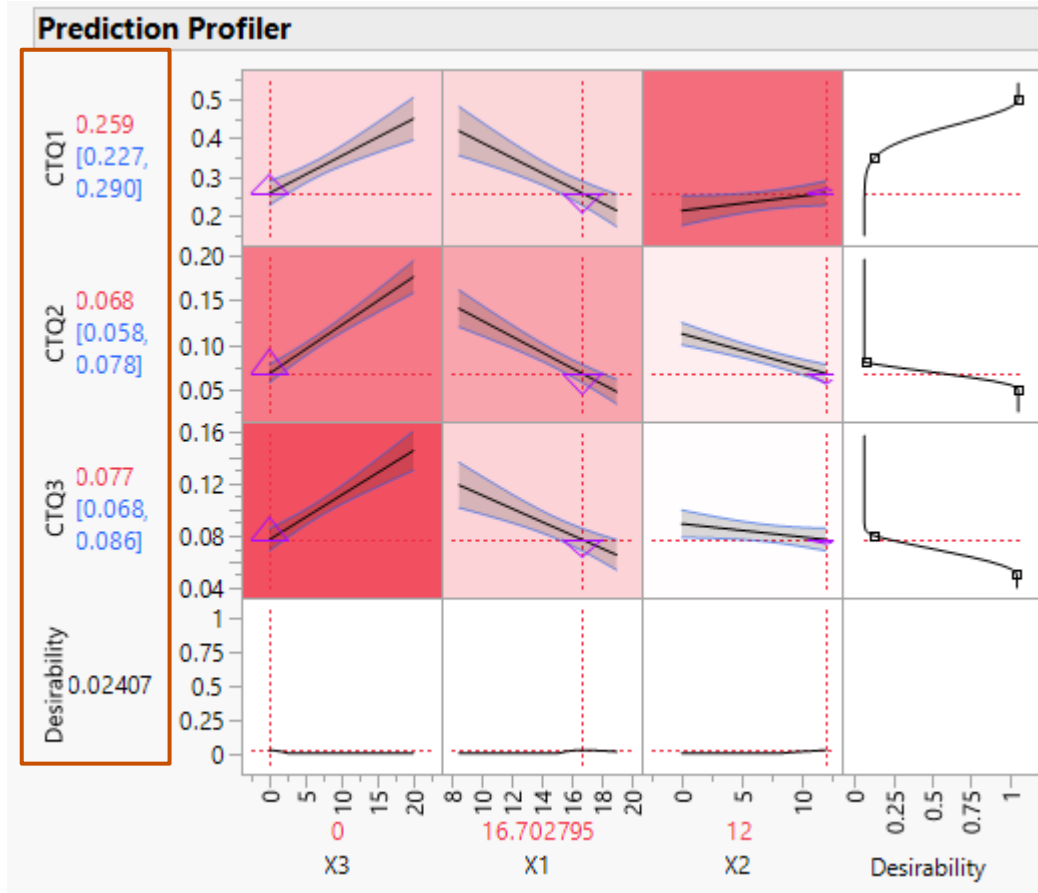


Hypothesis #2



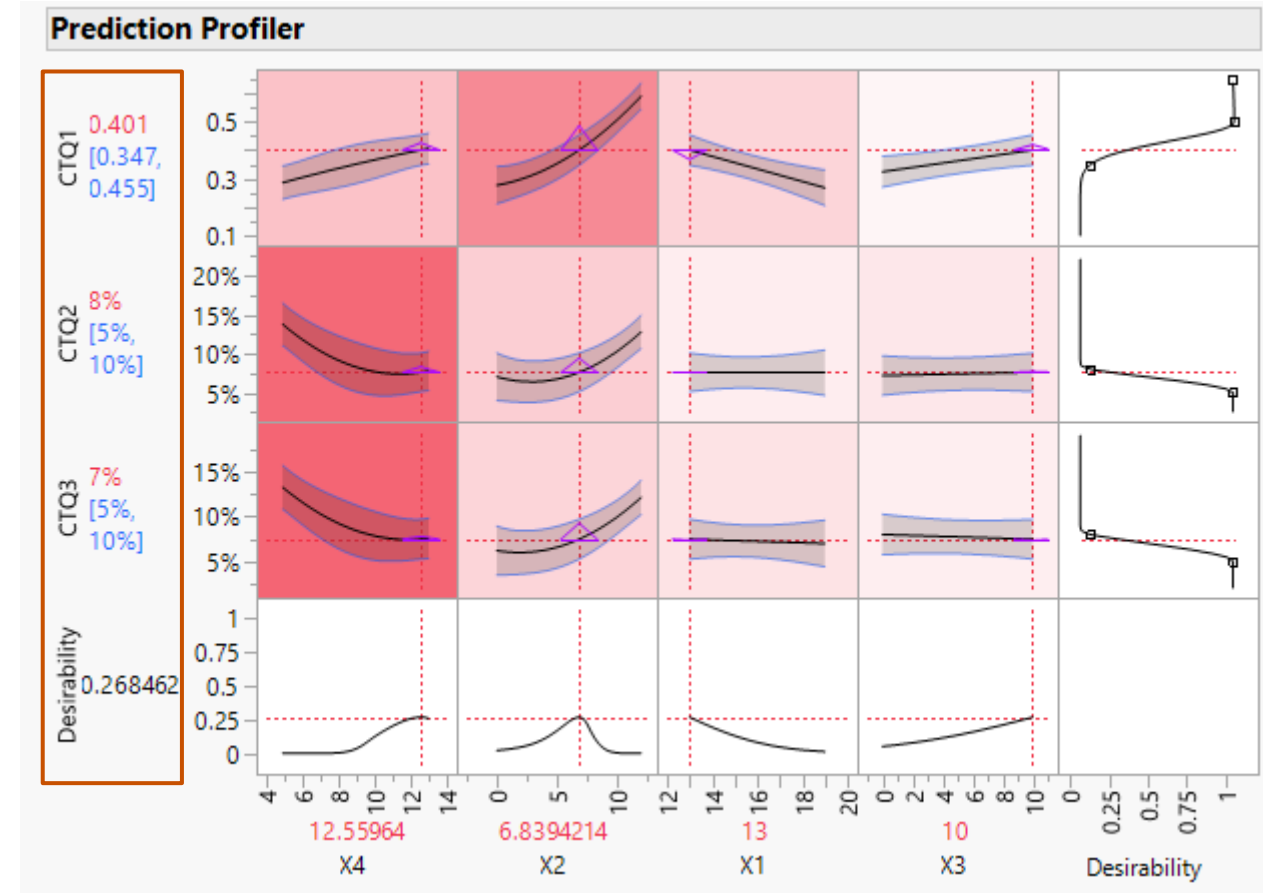
No optimized solution via desirability function, **BUT**

Baseline hardware (without X_4)

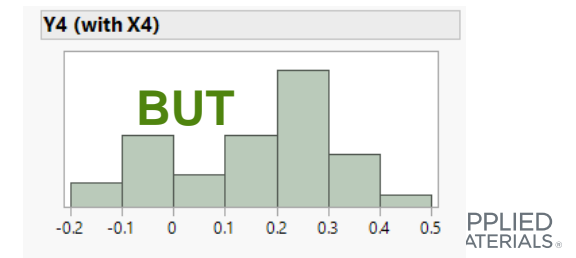


- ☹️ 0.02 desirable
- ☹️ no CTQ meet success criteria

Improved hardware (with X_4)



- 😊 Improved desirability
- ☹️ But still low (0.27)
- 😊 All CTQ improved
- ☹️ But not all meet requirement in one step



Potential solution: two step process

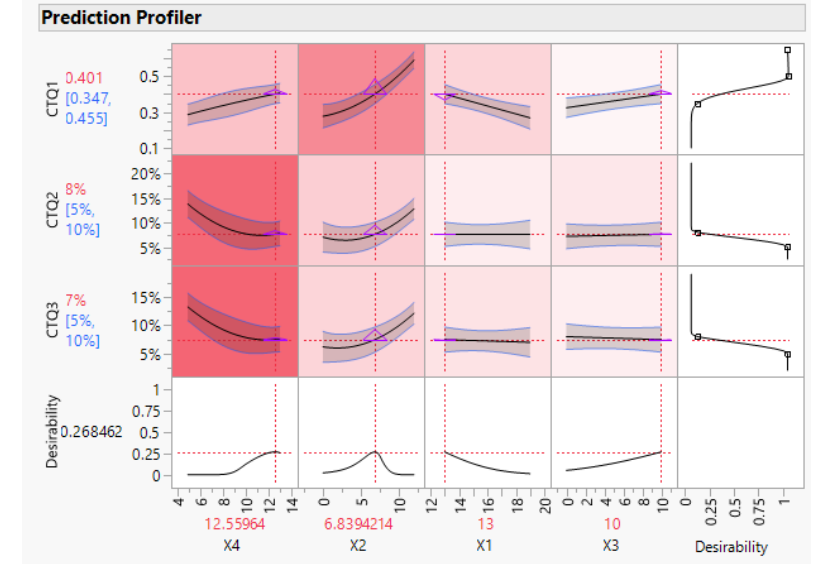
One step process



@ maximized desirability



- X_1
- X_2
- X_3
- X_4



A known model

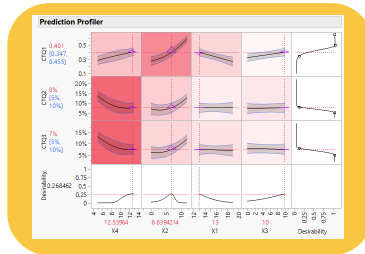
Two step process



process condition 1



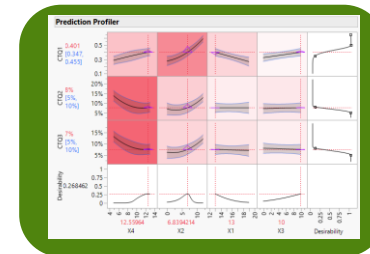
- X_1 1
- X_2 1
- X_3 1
- X_4 1
- Duration (1&2)



process condition 2



- X_1 2
- X_2 2
- X_3 2
- X_4 2
- Duration (1&2)

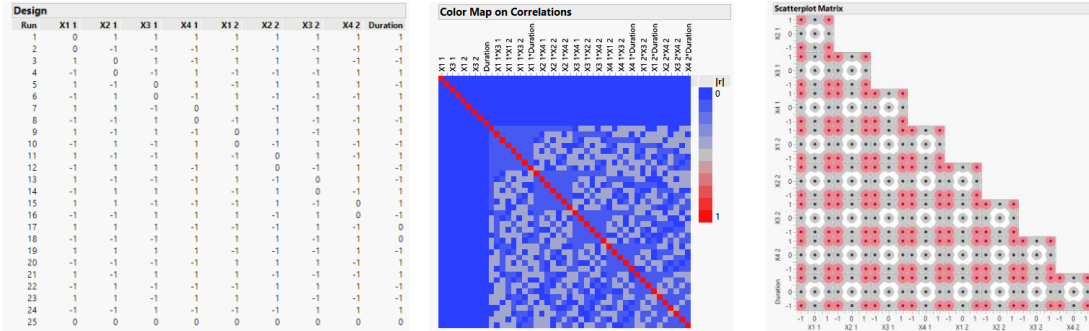


A new model

9 variables in total

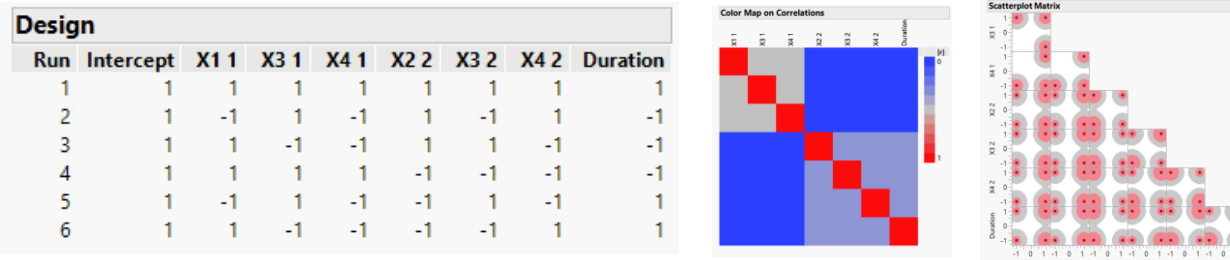
Two step process: strategies

Strategy 1: 9 variables with DSD modelling



- 25 runs at least for first trial
- Good orthogonal structure
- RSM model (9 variables) constructed
- High cost

Strategy 2: Group orthogonal super-saturated (GOSS) design



- 6 runs for 7 variables (super-saturated) (screen out 2 first: X₂ of step 1 and X₁ of step 2)
- Two independent blocks for each process step
- No interaction between factors cross blocks
- Orthogonal data structure in each block
- Main effect considered only
- Low cost
- May need further DOE design

DSD

- 17 runs
- High cost
- Interaction added

Augment DOE

- + 8 runs typically
- Medium cost
- Interaction added

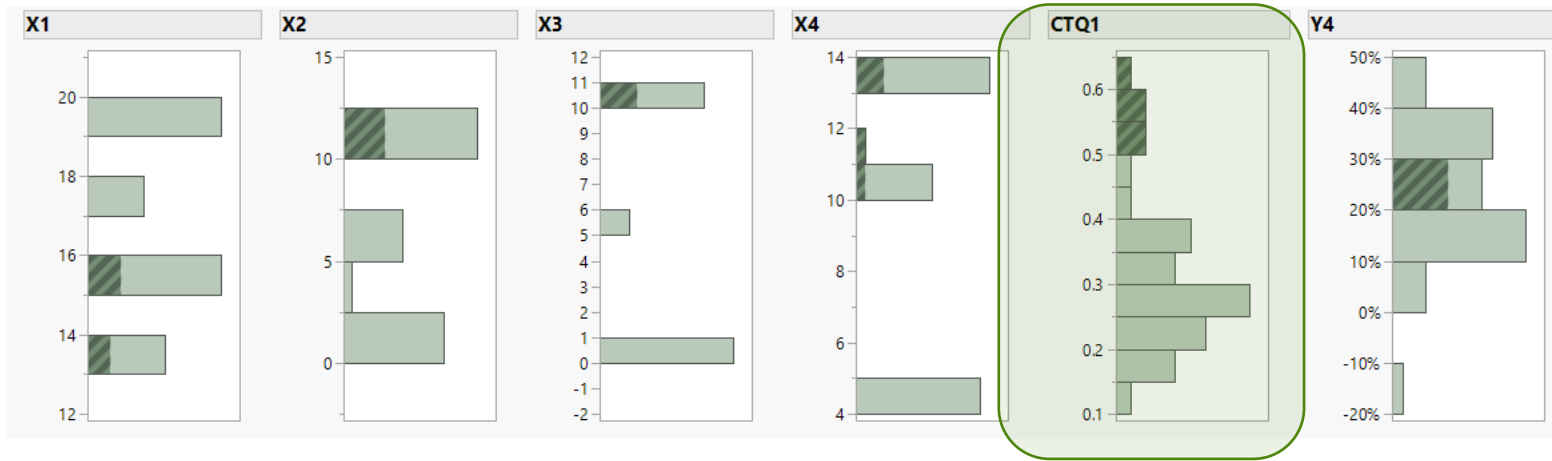
OFAT

- Valid without interaction
- Low cost
- One main effect only

Proceed with strategy 2: cost saving

Two-step process strategy: narrow down parameters

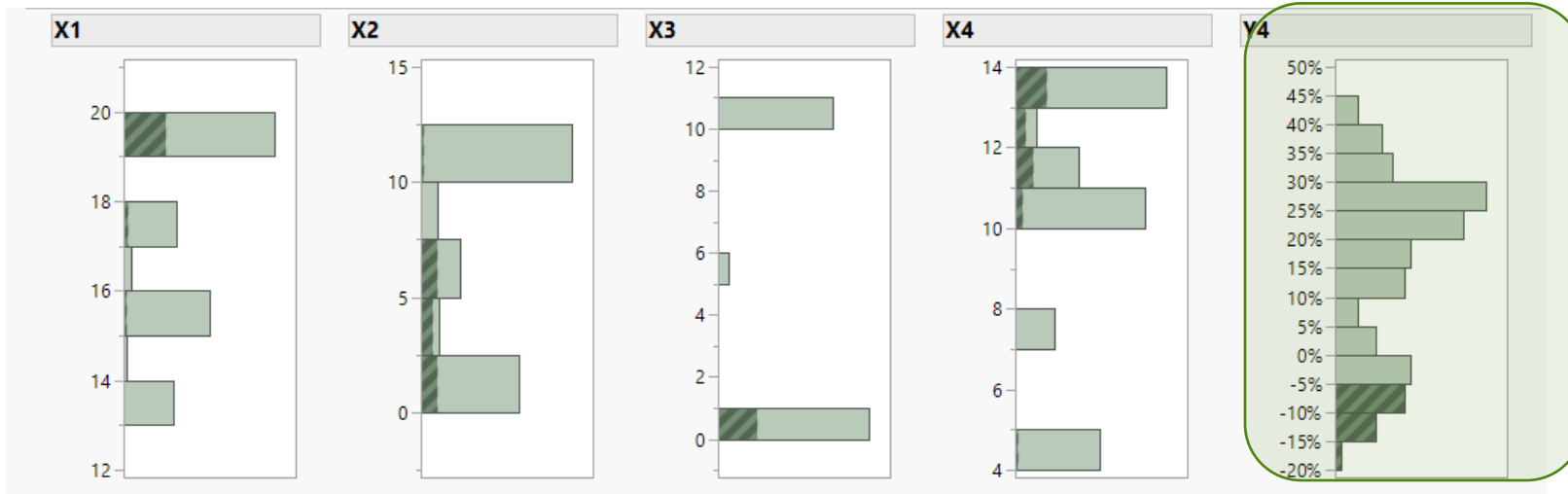
Step 1: CTQ1 > 0.5 (good for CTQ1)



Determined range for X_1, X_3, X_4 ; X_2 fixed

+ve process

Step 2: $Y_4 < -5\%$ (sum net process, good for CTQ2 and CTQ3)

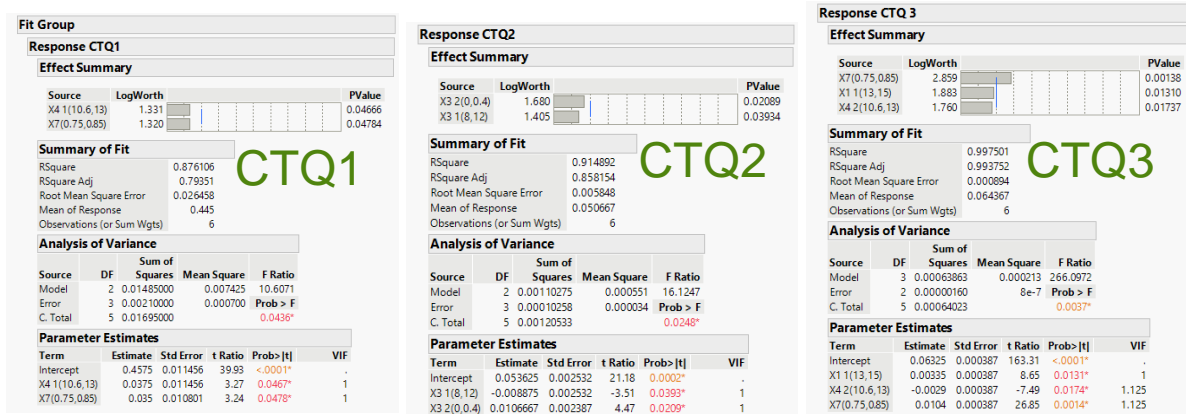


Determined range for X_2, X_3, X_4 ; X_1 fixed

-ve process

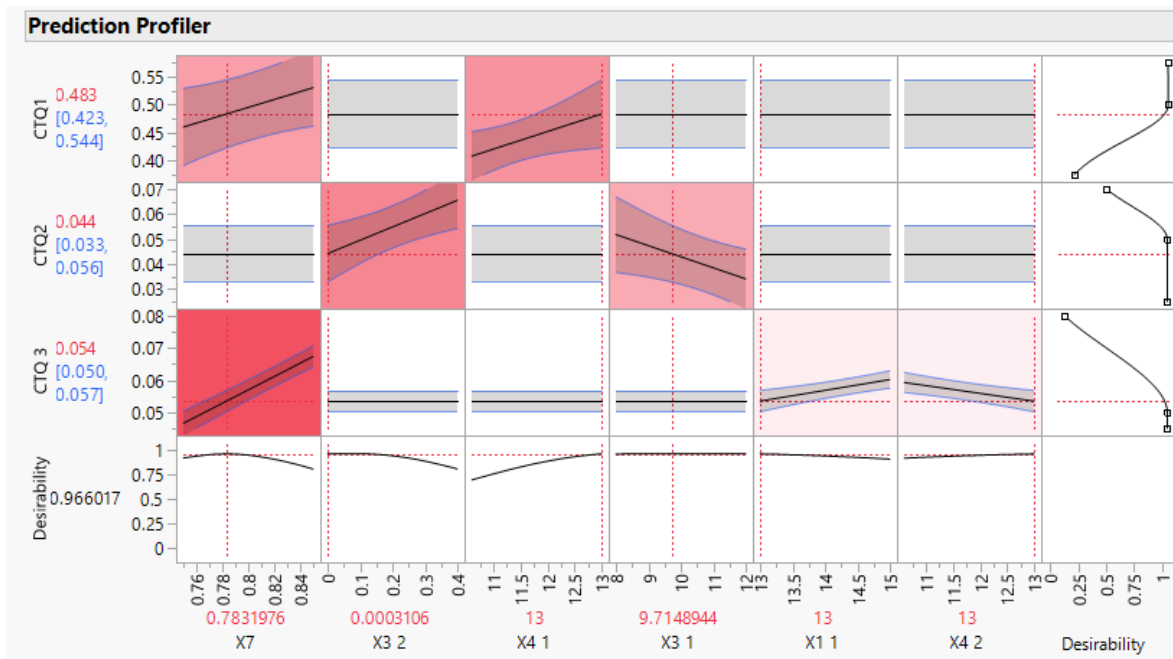
Modeling via stepwise after GOSS

Stepwise fit with main effect only



- Each CTQ has validated model (P<0.05)
- Rsquare Adj. ~0.8
- VIF<5

Optimized solution via desirability



- Provide with optimized solution with desirability > 0.96 (>>0.27>>0.02)
- Lock process parameter (high desirability)
- Next step: OFAT change duration for steps to find optimized

Summary

- Different JMP tools involved in data analysis throughout DMAIC project
 - Baseline capability analysis: Monte-Carlo simulation, Goal Plot
 - Root cause analysis: Multivariate Method, Graphic Analysis
 - DOE: Augment DOE, GOSS, Design Diagnostic
 - Model and prediction: Fitting, Prediction Profile, Interaction Profile
 - Screen condition of interest: Interactive Graph
 - Decision making: Desirability Function

Acknowledgement

- Thanks Charles C Chen's mentor



APPLIED
MATERIALS®

make possible